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## Photochemical reactions of 1-methoxymethylbicyclo[4.3.0]non-6-en-8-one and 5-methoxymethylbicyclo[3.3.0]oct-1-en-3-one

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## Abstract

Irradiation of the title compounds **5** and **6** with light of wavelengths 350 and 254 nm afforded products in different ratios. Abstractions of hydrogen atoms of the methoxyl groups by both  $C_{\alpha}$  and  $C_{\beta}$  are the primary photochemical reactions leading to various products, but the total yield of the products derived from  $C_{\beta}$  H-abstraction increased when light of wavelength 350 nm was used. Plausible mechanisms for the formation of the products are proposed. © 2000 Elsevier Science Ltd. All rights reserved.

The photochemical intramolecular hydrogen abstraction of cyclic  $\alpha,\beta$ -unsaturated ketones has attracted considerable attention.<sup>1</sup> Cyclohexenone 1, for instance, underwent  $C_{\alpha}$  H-abstraction upon  $\pi \rightarrow \pi^*$  excitation (254 nm) to give inter alia cyclic ether 2.<sup>2</sup> In contrast, cyclopentenone 3 underwent  $C_{\beta}$  H-abstraction upon  $n \rightarrow \pi^*$  excitation (>300 nm) to generate 4.<sup>3</sup> Our interest in the effect of ring size on the photochemical behavior of bicyclic enones<sup>4</sup> led to the investigation of the photochemistry of 5 and 6.<sup>5</sup> The results reveal that their photochemical reactions depend on the wavelength of incident light.



Compounds 5 and 6 exhibit UV absorption maxima at 223 ( $\varepsilon 1.3 \times 10^4$ ), 325 ( $\varepsilon 47$ ) nm and 222 ( $\varepsilon 1.7 \times 10^4$ ), 320 ( $\varepsilon 33$ ) nm, respectively. The deoxygenated solutions (purged with argon for 45 min) of 5 and 6 in isooctane (0.01 M) were irradiated either in Pyrex tubes with light of wavelength centered

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at 350 nm or in quartz tubes with light of wavelength at 254 nm with a Rayonet reactor. TLC analysis indicated that a complex mixture was produced in each case. Products were isolated and purified by means of flash chromatography, vacuum distillation (bulb-to-bulb) and recrystallization; the yields appear in Table 1. The structures of photoproducts **7–14** were assigned based on their IR, <sup>1</sup>H NMR, <sup>13</sup>C NMR and mass spectral data. The assignments of **9**, **10**, **11** and **14** were further confirmed by an X-ray diffraction method.<sup>6</sup> Compounds **9** and **14** are shown to be the *cis,anti,cis* head-to-tail dimers of **5** and **6**, respectively. 2-Cyclopentenone is known to give head-to-tail dimer as the major product, especially in dilute hydrocarbon solvent.<sup>7</sup>

Entry	Enone	hʊ/nm	Reaction Time/h	Conversion/%	Product (Yield/%)
1	5	350	10	91	<b>7</b> (44), <b>8</b> (2), <b>9</b> (9), <b>10</b> (3), <b>11</b> (7)
2	5	254	4	80	<b>7</b> (25), <b>8</b> (26), <b>9</b> (6)
3	6	350	10	86	<b>12</b> (51), <b>14</b> (4)
4	6	254	5	79	<b>12</b> (24), <b>13</b> (10), <b>14</b> (6)

 Table 1

 The conditions and yields of the photoproducts of 5 and 6 in isooctane



Plausible mechanisms for the formation of other photoproducts are given in Scheme 1. Products 8 and 13 are derived from the abstraction of a hydrogen atom of the methoxyl groups by the  $C_{\alpha}$  atoms of excited states of 5 and 6, respectively, via seven-membered-ring transition structures followed by ring closure of the ensuing diradicals 15a (*n*=2) and 15b (*n*=1). An alternative route for the formation of these two compounds via H-abstraction by the oxygen atoms is less likely because of sterically unfavorable

eight-membered-ring transition states. Compounds 7 and 12 are similarly produced through 16a (n=2) and 16b (n=1) from hydrogen abstraction by their C<sub>β</sub> atoms via six-membered-ring transition states. Compounds 10 and 11 are generated from enol ether 17 which is obtained from the ring closure of 16a with the formation of a C–O bond; the absence of parallel reactions for 16b is mainly due to a greater strain of the corresponding tricyclic enol ether. Intermediate 17, which is of a high strain, is expected to be very reactive because it possesses a bridgehead double bond<sup>8</sup> in a bicyclo[4.2.1]non-1(8)-ene system.<sup>9</sup> The dimerization of 17 gives 10 and the reaction of 17 with 5 yields 11. It is interesting to note that 10 and 11 possess distinctive regio- and stereochemistry; 10 is a *cis,syn,cis* head-to-head dimer, whereas 11 is a *cis,anti,cis* head-to-tail adduct. The cycloaddition to form 11 may be stepwise;<sup>9d</sup> the head-to-tail manner may be mainly due to a dipole–dipole interaction between the twisted enol ether moiety in 17 and the enone moiety in 5, whereas the *cis,anti,cis* arrangement may be attributed to a steric factor. The dimerization of 17 leading to 10 may also be stepwise;<sup>9d</sup> the head-to-head arrangement may be due to the ability of oxygen atoms to stabilize the diradical intermediate but an explanation for the preferential *syn* orientation is lacking.





That  $n \rightarrow \pi^*$  and  $\pi \rightarrow \pi^*$  excitations of **5** and **6** resulted in the formation of different types of products indicate that the reactions presumably proceed via distinctive excited states; however, further confirmation requires kinetic studies. The processes of  $C_{\alpha}$  and  $C_{\beta}$  H-abstractions are competitive; their relative rates depend on the ring size and the nature of excited states of **5** and **6**.  $C_{\alpha}$  H-abstraction is a less efficient process than  $C_{\beta}$  H-abstraction in the case of  $n \rightarrow \pi^*$  excitation as indicated by the absence of **13** and only 2% of **8**, but these two processes become compatible during  $\pi \rightarrow \pi^*$  excitation; the yields of **13** and **8** increase to 10 and 26%, respectively. It may be noted that neither product derived from  $C_{\alpha}$  H-abstraction of **3**<sup>3</sup> nor product from  $C_{\beta}$  H-abstraction of **1**<sup>2</sup> was reported. No attempt was made to investigate the nature of the excited states involved in the photochemical reactions of **5** and **6**; however, an  $n,\pi^*$  triplet and an upper (S<sub>2</sub>) state (upper triplet states cannot be excluded) were suggested to be responsible for  $C_{\beta}$  H-abstraction of **3**<sup>3</sup> and  $C_{\alpha}$  H-abstractions of **1**,<sup>2</sup> respectively.

The present study shows that the photochemistry of the title compounds depends on the wavelength of incident light. Both  $C_{\alpha}$  and  $C_{\beta}$  H-abstractions occur upon  $n \rightarrow \pi^*$  and  $\pi \rightarrow \pi^*$  excitations, but the relative percentage of  $C_{\beta}$  H-abstraction increases during  $n \rightarrow \pi^*$  excitation. A strained intermediate **17** underwent dimerization and [2+2] cycloaddition with cyclopentenone **5** in a distinctive regio- and stereochemical manner.

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